

3 The integrated circuit of claim 1, wherein the first bump, the second bump, and the reference bump for a bump structure that is repeated across a portion of the top metal layer.

4 The integrated circuit of claim 1, wherein the first metal bar is operatively connected to a voltage source, and wherein the second metal bar is operatively connected to ground.

5 The integrated circuit of claim 1, wherein the value of the angle is dependent on at least one selected from the group consisting of: a desired capacitance, a desired resistance, a desired inductance, a desired bump current flow, a desired bump population on the top metal layer, and desired signal track availability.

6 An integrated circuit having a top metal layer, the top metal layer having a first metal bar and a second metal bar, the integrated circuit comprising:

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a first bump disposed on the first metal bar;  
a second bump disposed on the first metal bar; and  
a reference bump disposed on the second metal bar,

wherein the first metal bar and the second metal bar are positioned such that an angle between a line from the reference bump to the first bump and a line from the reference bump to the second bump has a value substantially equal to 150 degrees.

7 The integrated circuit of claim 6, wherein the first bump, the second bump, and the reference bump form a bump structure that is repeated across the top metal layer to form a patterned bump array.

8 The integrated circuit of claim 6, wherein the first bump, the second bump, and the reference bump for a bump structure that is repeated across a portion of the top metal layer.

9 The integrated circuit of claim 6, wherein the first metal bar is operatively connected to a voltage source, and wherein the second metal bar is operatively connected to ground.

10 The integrated circuit of claim 6, wherein the value of the angle is dependent on at least one selected from the group consisting of: a desired capacitance, a desired resistance, a desired inductance, a desired bump current flow, a desired bump population on the top metal layer, and desired signal track availability.

11 A patterned bump array for a power grid of an integrated circuit, comprising:  
a reference bump disposed on a first metal bar;  
a first bump disposed on a second metal bar; and  
a second bump disposed on a second metal bar,  
wherein the first bump, the second bump, and the reference bump are arranged  
such that an angle between a line from the reference bump to the first  
bump and a line from the reference bump to the second bump has a  
value substantially equal to 150 degrees.

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A 1

12 The patterned bump array of claim 11, wherein the first metal bar and second metal bar form a portion of the power grid.

13 The patterned bump array of claim 11, wherein the first metal bar is operatively connected to power, and wherein the second metal bar is operatively connected to ground.

14 The patterned bump array of claim 11, wherein the arrangement of the first bump, the second bump, and the reference bump is repeated across the power grid.

15 The patterned bump array of claim 11, wherein the arrangement of the first bump, the second bump, and the reference bump is repeated across a portion of the power grid.

16 The patterned bump array of claim 11, wherein the value of the angle is dependent on at least one selected from the group consisting of: a desired capacitance, a desired resistance, a desired inductance, a desired bump current flow, a desired bump population on the top metal

layer, and desired signal track availability.

- 17 A bump layout for a power grid of an integrated circuit, comprising:
- a reference bump disposed on a first metal bar;
  - a first bump disposed on a second metal bar; and
  - a second bump disposed on a second metal bar,
- wherein the first metal bar and the second metal bar are arranged such that an angle between a line from the reference bump to the first bump and a line from the reference bump to the second bump has a value substantially equal to 150 degrees.

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- 18 The bump layout of claim 17, wherein the first metal bar and second metal bar form a portion of the power grid.
- 19 The bump layout of claim 17, wherein the first metal bar is operatively connected to power, and wherein the second metal bar is operatively connected to ground.
- 20 The bump layout of claim 17, wherein the arrangement of the first metal bar and the second metal bar is repeated across the power grid.
- 21 The bump layout of claim 17, wherein the arrangement of the first metal bar and the second metal bar is repeated across a portion of the power grid.
- 22 The bump layout of claim 17, wherein the value of the angle is dependent on at least one selected from the group consisting of: a desired capacitance, a desired resistance, a desired inductance, a desired bump current flow, a desired bump population on the top metal layer, and desired signal track availability.